

**21st Sensor Symposium
on Sensors, Micromachines and Applied Systems
October 14 - 15, 2004 Kyoto, Japan**

Thursday, October 14

	Rm A	Rm B	Rm C
10:00-11:50	Opening Session Invited Talk 1 Invited Talk 2		
11:50-13:00			
13:00-15:30	Session A1 Actuators	Session B1 Multi-Ferroic Materials: Fusion of Ferroelectric and Ferromagnetic	Session C1 Bio-Chemical Sensors
15:30-17:00	Poster Session		
17:00-18:00	Session A2 Actuators and Power MEMS	Session B2 Biometrics and Sensor Systems	Session C2 Odor and Gas Sensors
18:00-18:20			
18:30-20:00			

Friday, October 15

	Rm A	Rm B	Rm C
9:00-10:00	Session A3 Optical MEMS	Session B3 MEMS Foundry	Session C3 Materials
10:00-10:10			
10:10-10:40		Session B4 Nano-Technology and Emerging Technologies Sensing Systems 1	
10:40-10:50			
10:50-12:30	Session A4 Physical Sensors 1		Session C4 Processing Technology
12:30-13:30			
13:30-15:20	Session A5 Physical Sensors 2	Session B5 Sensing Systems 2	Session C5 Nano-Bio Fusion
15:20-15:40			
15:40-15:50			
15:50-17:00	Closing Session		

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Opening Session

PL-1 AmbientRT – Real Time, Data Centric System Software for Wireless Sensor Networks

S. Dulman, P. Havinga (University of Twente), T. Hofmeijer (Ambient Systems)

PL-2 MEMS Technology for Ubiquitous Sensor Network

K. Chun (Seoul National University)

Session A1 Actuators

A1-1 Monolithic PZT Microstage

H. G. Xu, T. Ono, M. Esashi (Tohoku University), K. Okamoto (NEC Tokin Corporation) and D. Y. Zhang (Beihang University)

A1-2 Microfabricated Quartz Crystal Resonator Array Developed for Measuring in Viscoelastic Liquids

L. Li, E. Sakata, M. Esashi, M. Nishizawa and T. Abe (Tohoku University)

A1-3 AlN Based Thin Film Bulk Acoustic Resonator with an Energy-Trapping Structure

M. Hara, T. Abe and M. Esashi (Tohoku University)

A1-4 High-Resolution Multi-View Stereoscopic Display with Vibrating Micromirrors

A. Nakai, K. Hoshino, K. Matsumoto and I. Shimoyama (The University of Tokyo)

A1-5 Applications of a Sequential Magnetic Self-Assembly

E. Iwase and I. Shimoyama (The University of Tokyo)

A1-6 Instability Analysis of Electrostatic Vertical Comb Drive Actuators

T. Takahashi, H. Fujita and H. Toshiyoshi (The University of Tokyo)

A1-7 Fabrication of Microactuator for Active Catheter from SMA Thin Film Tube

H. Kubo, M. Abe, T. Mineta, E. Makino (Hirosaki University) and T. Shibata (Ibaraki University)

Session A2 Actuators and Power MEMS

A2-1 Electrostatic Microactuator with Au/Poly-Si Bimorph Structure

Y. Kawamoto, T. Matsuda and T. Yasuda (Kyushu Institute of Technology)

A2-2 Fabrication of a Micro Reciprocating Engine for Power Generation

J. Ogawa, Y. Okada, T. Toriyama and S. Sugiyama (Ritsumeikan University)

A2-3 Development of MEMS-Based Ejectors and Their Application to Butane Combustion

D. Satoh, S. Tanaka and M. Esashi (Tohoku University)

A2-4 Fabrication of Flexible Thermopile Generator Sheet

M. Shiozaki, J. Ogawa, S. Hasebe, T. Toriyama, S. Sugiyama (Ritsumeikan University), H. Ueno and K. Itoigawa (Tokai Rika Co., Ltd.)

Session B1 Multi-Ferroic Materials: Fusion of Ferroelectric and Ferromagnetic

B1-1 Control of Ferroelectric Property of YMnO₃ Epitaxial Films by Magnetic Field

N. Fujimura, N. Shigemitsu, T. Yoshimura and A. Ashida (Osaka Prefecture University)

B1-2 Ferroelectric Properties and Related Microstructure in Multi-Ferroic Materials YMnO₃

S. Mori, Y. Horibe (Osaka Prefecture University), Y. Aikawa and
T. Katsufuji (Waseda University)

B1-3 Magnetic and Electric Properties of BaMO₃ (M: Co, Mn, Fe) Oxide

T. Inoue, T. Matsui, M. Miyai, N. Fujimura and K. Morii (Osaka Prefecture University)

B1-4 Preparation and Characterization of Multiferroic BiFeO₃ Thin Films Prepared by Pulsed Laser Deposition

K. Y. Yun, D. Ricinschi, M. Noda, S. Nasu and M. Okuyama (Osaka University)

B1-5 Structural Phase Transitions and Dielectric Anomaly in YFe₂O₄

S. Mori, K. Kishimoto, Y. Horibe (Osaka Prefecture University) and N. Ikeda (Spring-8)

B1-6 Preparation of Self-Assembled PbTiO₃ Nanostructures by Metalorganic Chemical Vapor Deposition and Their Ferro- and Piezo-Electric Properties

H. Fujisawa, M. Nagata, M. Shimizu, H. Niu (University of Hyogo),
H. Nonomura (Himeji Institute of Technology) and K. Honda (Fujitsu Laboratory Ltd.)

B1-7 Formation of Two-Dimensional Electron Gas and the Magnetotransport Behavior of ZnMnO/ZnO Heterostructure

A. Ashida, T. Edahiro, K. Masuko, T. Oshio and N. Fujimura (Osaka Prefecture University)

Session B2 Biometrics and Sensor Systems

B2-1 Face Understanding in the Ubiquitous Network Society

M. Sakuragi, Y. Ijiri, S. Hosoi and M. Kawade (Omron Corporation)

B2-2 A Cordless IrDA Fingerprint Identification Module for User Authentication Systems

T. Hatano, H. Morimura, S. Shigematsu, C. Yamaguchi, K. Machida and
Y. Okazaki (NTT Microsystem Integration Laboratories)

B2-3 Highly Sensitive CMOS MEMS Fingerprint Sensor

N. Sato, S. Shigematsu, H. Morimura, K. Machida (NTT Microsystem Integration Laboratories),
M. Yano, K. Kudou and T. Kamei (NTT Advanced Technology Corporation)

Session C1 Bio-Chemical Sensors

C1-1 Detection of Single Nucleotide Polymorphism Using Genetic Field Effect Transistor

T. Sakata and Y. Miyahara (National Institute for Materials Science)

C1-2 A Novel Filter-Less Fluorescence Detection Sensor Array for DNA Micro Chip

Y. Maruyama, K. Sawada, H. Takao and M. Ishida (Toyohashi University of Technology)

C1-3 Fluorescent Measurement of Nerve Cells by Using a Sub-Micron Aperture Plate

T. Kan, T. Kazawa, K. Matsumoto and I. Shimoyama (The University of Tokyo)

C1-4 Fabrication of pH Image Sensor for Biochemical Sensing

T. Hizawa, K. Sawada, H. Takao and M. Ishida (Toyohashi University of Technology)

C1-5 Dependence of Amperometric Biosensor Output on Structural and Conditional Parameters

M. Hashimoto, S. Upadhyay and H. Suzuki (University of Tsukuba)

C1-6 Detection of Heavy Metals by Evaporative Concentration Using Super Hydrophobicity

N. Nashida, I. Yanagimachi and H. Suzuki (University of Tsukuba)

C1-7 A New QCM Sensor Using Thickness-Twist-Mode

N. Okada, T. Kikuchi and Y. Osugi (NGK Insulators, Ltd.)

Session C2 Odor and Gas Sensors

C2-1 High Temperature and High Sensitivity NO_x Gas Sensor with Pt/SnO₂/SiC/Ni Hetero-Junction Devices

W. Gao, S. A. Khan, Y. Hasegawa, L. Shi and T. Katsube (Saitama University)

C2-2 Integrated Ammonia Sensing System with a Microfluidic Transport System Based on Electrowetting

W. Satoh and H. Suzuki (University of Tsukuba)

C2-3 Study of Halitosis-Substance Sensing Using Electrochemical Sensor Array Combined with a Preconcentrator

T. Nakamoto, K. Kobayashi (Tokyo Institute of Technology) and
J. Ito (Tokyo Medical and Dental University)

C2-4 Sensing Probe for Three-Dimensional Gas-Source Localization Using Ultrasonic Anemometer

K. Yoshikawa, T. Moriizumi (Tokyo Institute of Technology) and
H. Ishida (Tokyo University of Agriculture and Technology)

Poster Session

P-1 Selective Growth of Carbon Nanotubes by Self-Assembled Monolayer Patterning

Y. Takei, K. Hoshino, K. Matsumoto and I. Shimoyama (The University of Tokyo)

P-2 Fabrication of a Micro Fluidic Sensor System for the Determination of GOT and GPT Activities

N. Ohgami, S. Upadhyay, H. Suzuki (University of Tsukuba) and
H. Kusakabe (Yamasa Corporation)

P-3 The Measurement of the Aquatic Environment by Using Surfactant Sensor

M. Matsushita, M. Kikuchi (Keio University) and S. Shiratori (SNT Co., Ltd.)

P-4 Observation of the Surface of Lipid/Polymer Membrane of Taste Sensor

H. Shimakawa, M. Habara and K. Toko (Kyushu University)

P-5 Hierarchical Signal Processing for Flavor Taste Sensor

S. Umetani, Y. Hasegawa and T. Katsube (Saitama University)

P-6 Compensating Method for the Output of QCM Gas Sensor

M. Kikuchi, T. Ito (Keio University) and S. Shiratori (SNT Co., Ltd.)

P-7 Analysis of Bioelectrical Potential of Plants: Environmental Influence

Y. Hasegawa, T. Yamanaka and T. Katsube (Saitama University)

P-8 Micropatterning and Micromolding by Using Sputter Deposited Photocatalytic Film

E. Sakata, M. Esashi, M. Nishizawa and T. Abe (Tohoku University)

P-9 Fabrication of Single-Sided Gate JFET for Sensor Interface Circuit on Si (111)

Y. Kato, T. Hashimoto, Y. C. Liew, H. Takao, K. Sawada and
M. Ishida (Toyohashi University of Technology)

P-10 3-D Micro-Machining Technique by Double Exposure in Normal Deep X-ray Lithography

N. Matsuzuka (Ritsumeikan University), Y. Hirai and O. Tabata (Kyoto University)

P-11 Anisotropic Etching Simulation of Silicon Using Interatomic Bond Cutting Probability

T. Kakinaga, N. Baba, Y. Isono (Ritsumeikan University),
O. Tabata (Kyoto University) and J. G. Korvink (University of Freiburg)

P-12 Electrodeposition Technology of Organic Films with Selective Coating for MEMS Structure

T. Sakata, H. Ishii, Y. Okabe, N. Sato, K. Machida (NTT Microsystem Integration Laboratories),
M. Yano, K. Kudou and T. Kamei (NTT Advanced Technology Corporation)

P-13 A Study for Surface Roughness Modification of Three Dimensional Structures Fabricated by Emulsion Gray-Scale Mask

R. Mori, K. Hanai and Y. Matsumoto (Keio University)

P-14 Local Machining with nm Order Precision by Using FIB

S. Ogura, J. Makinodan, S. Konishi (Ritsumeikan University),
Y. Nakashima and T. Yasuda (Kyushu Institute of Technology)

P-15 A Water-Repellent Silanization Coating Technique for MEMS

K. Shimaoka, H. Hosokawa, H. Funabashi and Y. Mitsushima
(Toyota Central Research and Development Laboratories, Inc.)

P-16 Fabrication of Plastic Microneedle Array Using Laser Micromachining of Nanoparticles Dispersed Polymer and Micromolding

H. Yagyu, S. Hayashi (Mitsuboshi Belting Ltd.) and O. Tabata (Kyoto University)

P-17 Characterizations of the Shocked-BPSCCO (Bi-Pb-Sr-Ca-Cu-O) Superconducting Particles for Making a Magnetic Sensor

K. Yamagata, Y. Maeji, T. Yamada, M. Itoh (Kinki University),
H. Kezuka (Tokyo University of Technology), M. Kikuchi (Tohoku Fukushi University),
T. Atou, M. Kawasaki, K. Fukuoka (Tohoku University) and T. Suzuki (Tokai University)

P-18 Mechanical Strength of Quartz Micromechanical Devices

F. Kohsaka, J. Liang and T. Ueda (Waseda University)

P-19 Young's Modulus Control of the Micro Cantilever Made by Micro-Stereolithography

M. Miwa, K. Douoka, S. Tuchitani, Y. Koshimoto, R. Kaneko (Wakayama University) and
S. Yoneyama (Osaka Prefecture University)

P-20 Synthesis and Properties of $\text{Bi}(\text{Fe}_x\text{Al}_{1-x})\text{O}_3$ Multi-Ferroic Thin Films

N. Fujimura, M. Okada, A. Ashida and T. Yoshimura (Osaka Prefecture University)

- P-21 XY Surface Acoustic Wave Motor with Nanometer Resolution**
T. Shigematsu and M. K. Kurosawa (Tokyo Institute of Technology)
- P-23 Simple Fabrication Process for Surface Micromachining Using Sputtered Oxide as Sacrificial Layer and Its Application**
N. Shimamoto, S. Okamoto, Y. Matsushita, T. Fujita, K. Maenaka and Y. Takayama (University of Hyogo)
- P-24 A New Thermal Isolation Structure by a Surface Bulk Micromachining for Dielectric Bolometer Mode IR Sensor**
M. Matsumoto, S. Murakami (Technology Research Institute of Osaka Prefecture), D. Popovici, M. Noda and M. Okuyama (Osaka University)
- P-25 Fabrication of Submicron-Scale MEMS Switch by Using Silicon Process**
K. Yamanaka and Y. Goto (Hitachi Ltd.)
- P-27 Research on Development of Tactile Sensor for Clinical Application**
K. Sakamoto and S. Omata (Nihon University)
- P-28 Designing Structures of Sensor Networks by the Highly Optimized Tolerance Model**
T. Miyano (Ritsumeikan University) and M. Yamakoshi (Hokkaido University)
- P-29 Micro Wind Tunnel Type Anemometer Using a Micro-Air-Bridge Heater**
S. Yasaka, M. Mitsuhashi, S. Kaneko, K. Ito, S. Ohya (Kanagawa Industrial Technology Research Institute), Y. Kanno (I Denshi Giken Co., Ltd.), Y. Aikyo, S. Komuro, K. Ohbayashi (Flat Electronics Co., Ltd.) and M. Kimura (Tohoku Gakuin University)
- P-30 Remote Sensing of Strain Using Passive SAW Devices**
T. Nomura and A. Saitoh (Shibaura Institute of Technology)
- P-31 Proposal of Injected Carrier Transport-Modulation Type Magneto-Transistor**
S. Takahashi and M. Kimura (Tohoku Gakuin University)
- P-32 Surface Acoustic Wave Optical Deflector for Surface Plasmon Resonance Sensor**
T. Takahata, K. Hoshino, K. Matsumoto and I. Shimoyama (The University of Tokyo)
- P-33 Optimal Design of a Small Position Sensor with Low Temperature Drift**
K. Nagai, S. Nakanishi (Ritsumeikan University), R. Fujimoto (Matsushita Electric Inc.), N. Oshie and S. Hatakeyama (LEVEX Inc.)
- P-34 Noise Squeezed Resonant Infrared Sensor**
H. Wakamatsu, T. Ono and M. Esashi (Tohoku University)
- P-35 Drag Force Flow Sensor Using Micro Laser Interferometer**
Z. Yang (Tokyo Metropolitan Industrial Technology Research Institute), S. Matsumoto, J. Tsaur and R. Maeda (The National Institute of Advanced Industrial Science and Technology)
- P-36 Characterization of Native-Substrate MAGFETs for a CMOS Smart Rotary Encoder**
T. Takahashi (NTN Corporation), K. Nakano and S. Kawahito (Shizuoka University)

- P-37 Sensitivity Optimization of the Micro Tactile Sensor**
Y. Murayama and S. Omata (Nihon University)
- P-38 High Sensitive Silicon Mass Sensor in Viscous Environment**
S. J. Kim, T. Ono and M. Esashi (Tohoku University)
- P-39 Early Fire Detection Using Gas Sensing Array and Its Application to Mobile Robot**
T. Tashiro, Y. Takei, T. Misawa, H. Nanto (Kanazawa Institute of Technology),
H. Kasahara (New Cosmos Electric Co., Ltd.) and Y. Iwasaki (tmsuk Co., Ltd.)

Session A3 Optical MEMS

- A3-1 Resolution Improvement of Absorption Photometry Microchip with Optical Path Using 45° Mirrors**
T. Noda, H. Takao, M. Ashiki, K. Sawada and M. Ishida (Toyohashi University of Technology)
- A3-2 Measurement of the Blood Absorbance Using a Micro Fabry-Perot Interferometer**
T. Dohi, K. Matsumoto and I. Shimoyama (The University of Tokyo)
- A3-3 Low-Insertion-Loss and Compact 3D-MEMS Optical Matrix Switch with Flexible Configuration within 18 Input/Output Ports**
A. Kazama, M. Horino, K. Fukuda, M. Kanamaru, T. Akashi, T. Ishikawa, T. Harada, R. Okada (Hitachi, Ltd.) and Y. Itou (Hitachi Metals, Ltd.)
- A3-4 A Fabrication Process and Design of High-Yield and Low-Voltage-Operation Micromirror for Optical MEMS Switches**
M. Urano, H. Ishii, T. Minotani, T. Shimamura, T. Sakata, Y. Tanabe, K. Machida (NTT Microsystem Integration Laboratories),
T. Kamei, K. Kudou and M. Yano (NTT Advanced Technology Corporation)
- A3-5 Ultra Compact Optical Subassembly Using Silicon Microlens**
Y. Maeno, H. Sasaki, D. Shimura, M. Uekawa, K. Kotani, R. Sekikawa and T. Takamori (Oki Electric Industry Co., Ltd.)

Session A4 Physical Sensors 1

- A4-1 Properties and Applications of Sn-Doped InSb Single Crystal Thin Film Magnetoresistance Elements**
K. Nishimura, H. Goto, S. Yamada, H. Geka, A. Okamoto and I. Shibasaki (Asahikasei Corporation)
- A4-2 Improvement of Electron-Emission-Type Infrared Sensor Using Ferroelectric Materials**
D. Takamuro, H. Takao, K. Sawada and M. Ishida (Toyohashi University of Technology)
- A4-3 Silicon-MEMS Smart Tactile Image Sensor with Device Flexibility and Wide Input-Force Range**
H. Takao, K. Sawada and M. Ishida (Toyohashi University of Technology)
- A4-4 Sensitivity Change Induced by Static Deflection of Diaphragm in Piezoelectric Ultrasonic Microsensor**
H. Nishimoto, K. Yamashita and M. Okuyama (Osaka University)
- A4-5 Force Measurement System Using Piezoresistive Force-Sensing Cantilevers for**

Evaluating Binding Force between Micro-Scale Flat Surfaces in Aqueous Solution
H. Onoe, M. Gel, K. Hoshino, K. Matsumoto and I. Shimoyama (The University of Tokyo)

Session A5 Physical Sensors 2

- A5-1 Bulk-Micromachined Vibratory Accelerometer and Their Peripheral Circuitry**
K. Maenaka, N. Sawai, M. Kozuki, S. Ioku, T. Fujita and Y. Takayama
(Himeji Institute of Technology)
- A5-2 Design & Fabrication of Miniaturized Piezoresistive Six-Degree of Freedom Accelerometer**
R. Amarasinghe, D. V. Dao, T. Toriyama and S. Sugiyama (Ritsumeikan University)
- A5-3 Study on Resonant Frequency of an Accelerometer Utilizing a Parylene Suspended Structure**
D. Yoshikawa, S. Aoyagi, K. Makihiro, M. Takano (Kansai University) and
Y.-C. Tai (California Institute of Technology)
- A5-4 Bulk MEMS Gyroscope with Tuning Fork Structure**
S. Ioku, H. Araki, H. Kohara, T. Fujita, K. Maenaka and Y. Takayama (University of Hyogo)
- A5-5 5-Axis Motion Sensor with SOI Structure Using Resonant Drive and Non-Resonant Detection Mode**
Y. Watanabe, T. Mitsui (Yamagata Research Institute of Technology) and
T. Mineta (Hiroshima University)
- A5-6 Development of 6-Axis Motion Sensors Using Piezoelectric Elements**
K. Okada, T. Kakutani, H. Itano, Y. Matsu (Wacoh Corporation) and
S. Sugiyama (Ritsumeikan University)

Session B3 MEMS Foundry

- B3-1 Current Issues of MEMS Foundry Network in Japan (Introduction of MEMS Foundry Service Industry Committee)**
T. Mihara (Olympus Corporation)
- B3-2 MEMS Foundry in AIST -Speedy Realization of New Ideas-**
R. Maeda, M. Takahashi and T. Eiju (National Institute of Industrial Advanced Science and Technology)

- B3-3 Bulk-MicroMachining Multichip Project (BM³P)**
T. Fujita, S. Ioku, K. Maenaka and Y. Takayama (University of Hyogo)

**Session B4 Nano-Technology and Emerging Technologies
Sensing Systems 1**

- B4-1 Fabrication of a Microfluidic Device for Axonal Guidance**
Y. Nakashima and T. Yasuda (Kyushu Institute of Technology)
- B4-2 Development of Multi-Probe Cantilever for Scanning Probe Nanolithography**
Y. Takagi, T. Watanabe and Y. Isono (Ritsumeikan University)
- B4-3 Diamond Films for FED Fabricated by Using Spin Coat Seeding**
Y. Matsuba, S. Tezuka and K. Takahashi (Saitama University)

- B4-4 Transmission Electron Microscope Observation and Measurement of Tunnel Current between Opposing Electrodes**
T. Ishida, K. Kakushima and H. Fujita (The University of Tokyo)
- B4-5 Fundamental Study of Remote Stiffness Testing in an Application for Intravascular Tactile Sensor**
M. Haruta and S. Omata (Nihon University)
- B4-6 Research for Hardness Measurements Using X-ray Computed Tomography**
T. Nomura and S. Omata (Nihon University)
- B4-7 Development of Breast Cancer Checker Using New Tactile Sensors**
S. Omata, Y. Murayama (Nihon University) and C. E. Constantinou (Stanford University)

Session B5 Sensing Systems 2

- B5-1 Real-Time 3D Imager Using Spatio-Temporal Phase Unwrapping**
N. Ono, T. Shimizu, T. Kurihara and S. Ando (The University of Tokyo)
- B5-2 Real-Time En-face Optical Coherence Tomography Using Correlation Image Sensor**
T. Shimizu, T. Kurihara, N. Ono, S. Ando (The University of Tokyo) and K. Kitagawa (Toray Engineering Co., Ltd.)
- B5-3 Equi-Distance Tracking of a Preceding Target by Using a Monocular Active Camera**
Y. Makino and W. Mitsuhashi (The University of Electro-Communications)
- B5-4 The Ground Temperature Distribution in Water Drip Measured by Infrared Camera**
D. Noda, K. Sawada, M. Ishida (Toyohashi University of Technology) and T. Itoh (Japan Operator Co., Ltd.)
- B5-5 Magnetically Driven Active Tactile Sensor for Hardness Detection**
Y. Hasegawa, H. Sasaki, M. Shikida, S. Kuriyama, K. Sato (Nagoya University) and K. Itoigawa (Tokai Rika Co., Ltd.)

Session C3 Materials

- C3-1 Fatigue Damage Evaluation of MEMS Materials Using Full-Reversed Bending Fatigue Tester**
H. Kito, T. Kikuchi and Y. Isono (Ritsumeikan University)
- C3-2 Pyrolyzed-Polyimide for MEMS Application**
K. Naka, H. Nagae, M. Ichiyanagi and S. Konishi (Ritsumeikan University)
- C3-3 Ferroelectrics Properties of Epitaxial $\text{Pb}(\text{Zr}_x, \text{Ti}_{1-x})\text{O}_3$ Thin Films on Epitaxial $\text{Pt}/\text{-Al}_2\text{O}_3/\text{Si}$ Substrates**
D. Akai, M. Yokawa, K. Hirabayashi, K. Matsushita, K. Sawada and M. Ishida (Toyohashi University of Technology)
- C3-4 Microbonding of $\text{Pb}(\text{Zr,Ti})\text{O}_3$ Bulk Ceramics to Si Single Crystals**
K. Tanaka, W. Kuze, T. Konishi, A. Shimazu and S. Sugiyama (Ritsumeikan University)
- C3-5 Glass Press Mold Fabricated by SiC APCVD, SiC-SiC Bonding and Silicon Lost Molding**
K.-O. Min, S. Tanaka and M. Esashi (Tohoku University)

Session C4 Processing Technology

C4-1 Characteristics of Silicon Nitride Reaction to Anhydrous HF Gas Treatment

K. Shimaoka, H. Funabashi and Y. Mitsushima
(Toyota Central Research and Development Laboratories, Inc.)

C4-2 Simulation of Surface Roughness in Si Etching with XeF₂

K. Sugano and O. Tabata (Kyoto University)

C4-3 Controlling of Isotropic and Anisotropic Etchings in KOH Solution by Applying Voltage

S. Yamashita, H. Tanaka, Y. Abe (Denso Corporation) and
K. Inoue (Toyota Central Research and Development Laboratories, Inc.)

C4-4 Improvement in Smoothness of Anisotropically Etched Silicon Surface: Effects of Surfactant and TMAH Concentration

D. Cheng, T. Hori, K. Sato and M. Shikida (Nagoya University)

C4-5 Alignment X-ray Lithography for Hole Perforating through PCT-Microneedle

S. Khumpuang, M. Horade, K. Fujioka and S. Sugiyama (Ritsumeikan University)

Session C5 Nano-Bio Fusion

C5-1 Reversing Single F₁-Motor Protein in Micro Chambers

H. Noji, Y. Rondelez, G. Tresset, Y. H. Arata, H. Fujita and S. Takeuchi
(The University of Tokyo)

C5-2 Planar Lipid Bilayer Array Chip Using Micro Fluidic System

H. Suzuki, K. Tabata, H. Noji and S. Takeuchi (The University of Tokyo)

C5-3 Electrostatic Immobilization of Biomolecules with an Array of 3D Nano-Electrodes

T. Yamamoto and T. Fujii (The University of Tokyo)

C5-4 Narrow Gap DNA Tweezers for Retrieval of Short Strand DNAs

J. Yamamoto, M. Hosogi, G. Hashiguchi (Kagawa University),
K. Tamura, K. Kakushima and H. Fujita (The University of Tokyo)

C5-5 Towards Sensing and Imaging with a Photothermally Actuated Cantilever Array

T. Nakazawa, T. Mutsuo, S. Kawai, Y. Hoshi, H. Toshiyoshi, H. Kawakatsu
(The University of Tokyo), D. Kobayashi (Japan Science and Technology Agency),
K. Nakagawa, M. Miyake and G. Hashiguchi (Kagawa University)

C5-6 Fabrication of Twin Microcantilever Array for Measurement of Red Blood Cell Deformability and Electrical Impedance

Y. Cho, N. Takama and B. J. Kim (The University of Tokyo)

Closing Session